



Microwave sintering of $\text{Ba}_{0,6}\text{Sr}_{0,4}\text{TiO}_3$ Thick-Films

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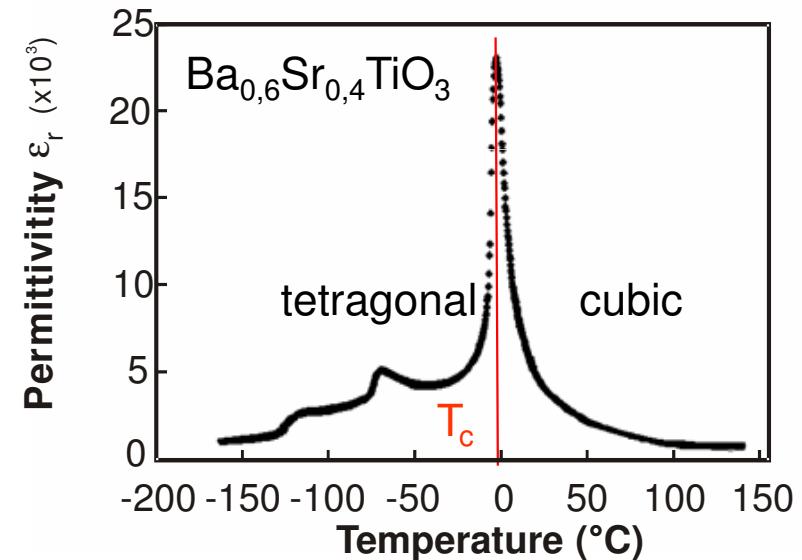
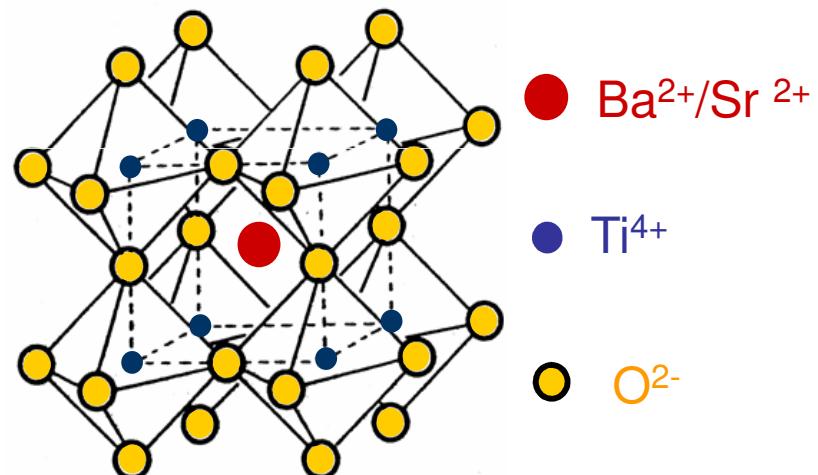
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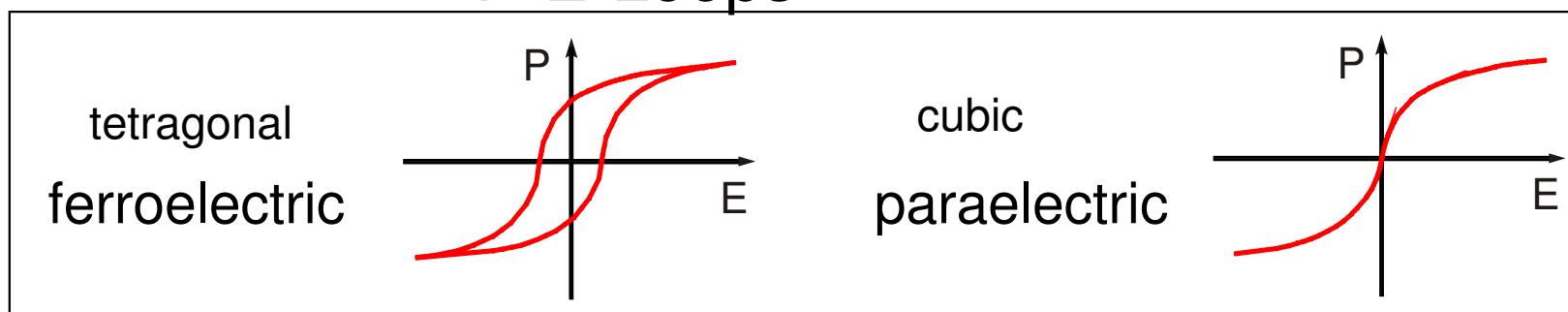


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Introduction



P-E-Loops

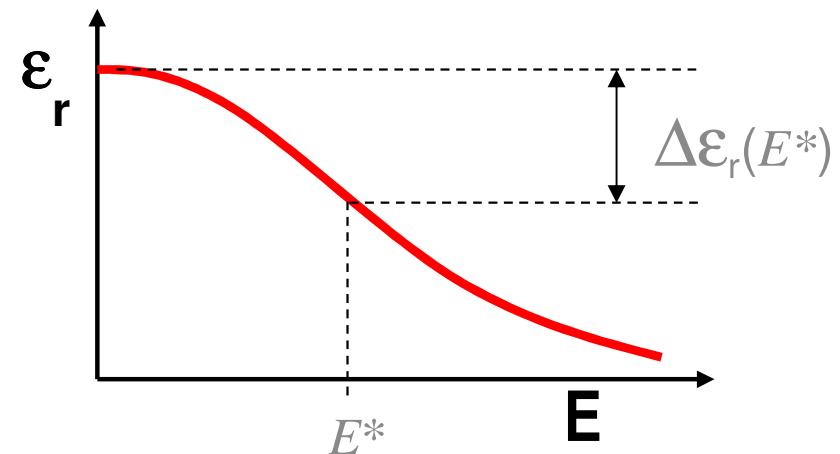
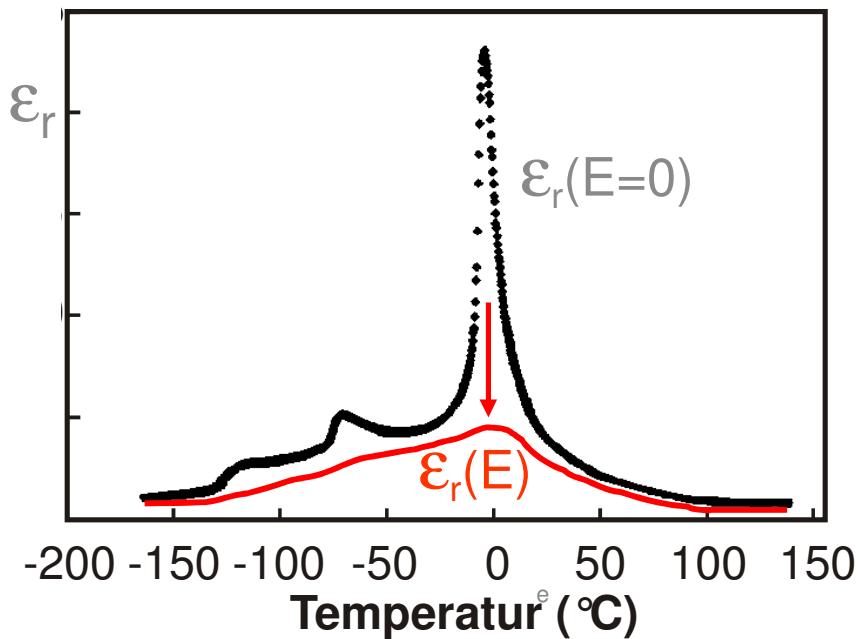


Introduction

Decrease of permittivity

tunability : decrease of permittivity through external el. field

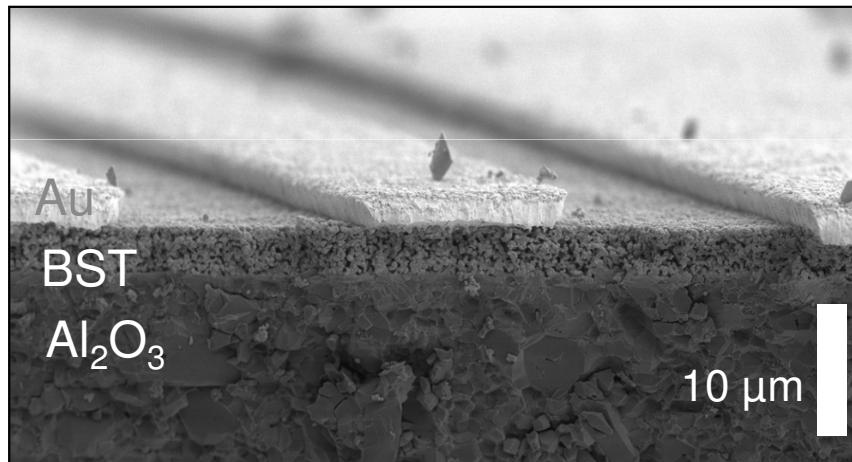
$$\text{tunability } \tau(E^*) = \frac{\Delta\epsilon_r(E^*)}{\epsilon_r(E=0)}$$



Motivation

functionality

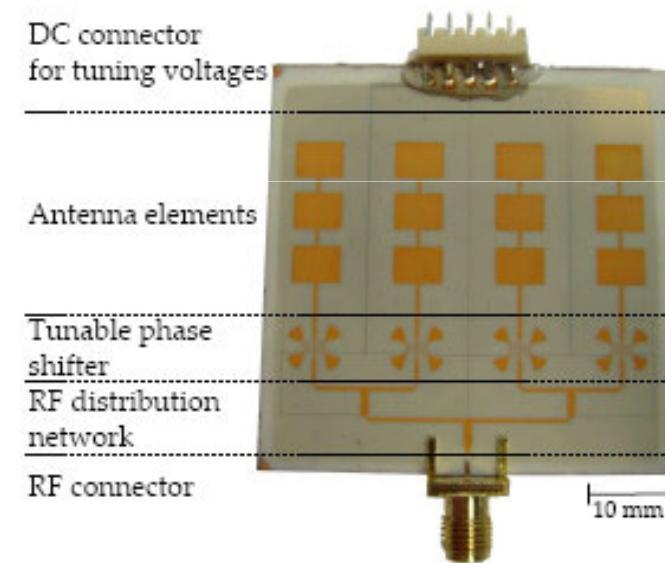
- permittivity of $\text{Ba}_{0.6}\text{Sr}_{0.4}\text{TiO}_3$ shows nonlinear tunability under static E-field



cross-section of coplanar
waveguide

application

- tunable RF-components
- reconfigurable circuits
- phaseshifters (delay lines)
- electronically steerable oscillators & filters



passive phase array antenna

Microwave sintering (MWS)

conventional



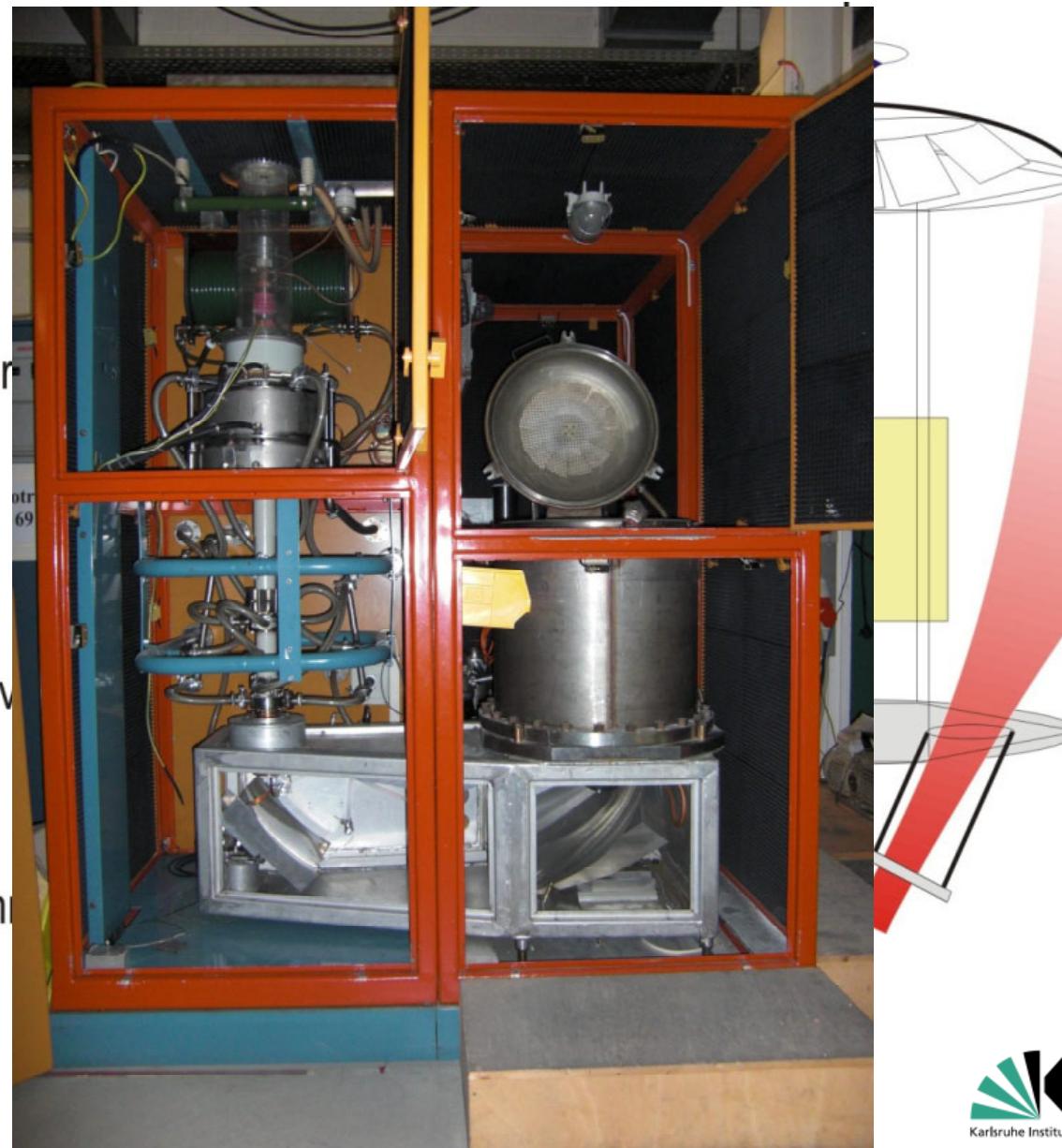
- heating from „outside“ in conventional sintering

microwave

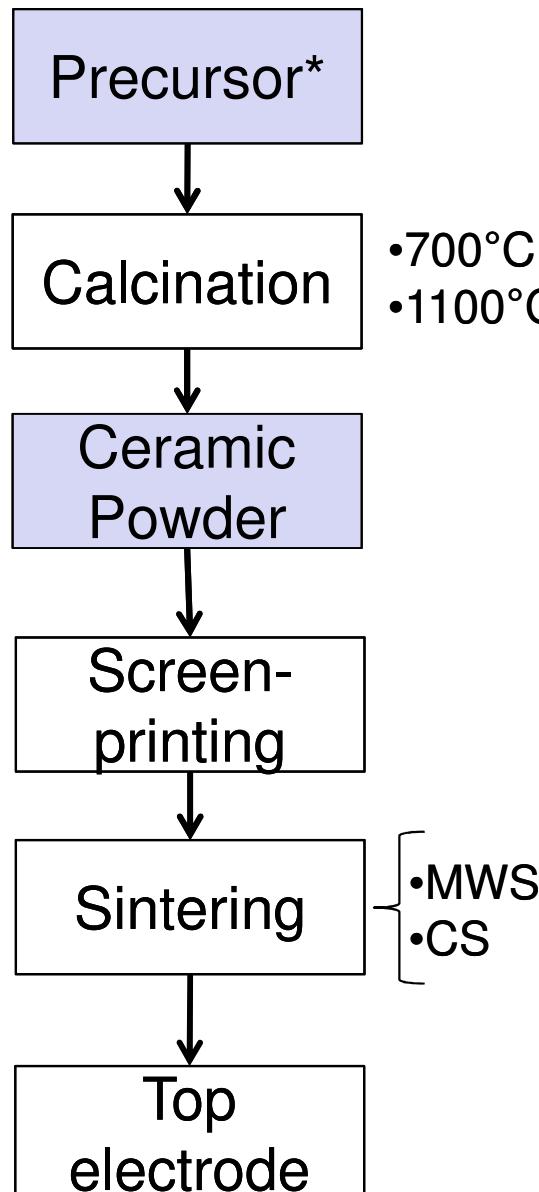


- inverse heating profile in MWS
- regions with high dielectric loss heat up stronger
- short processing time and high heating rates

Microwave sintering (MWS)

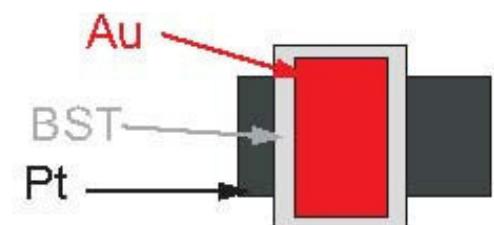
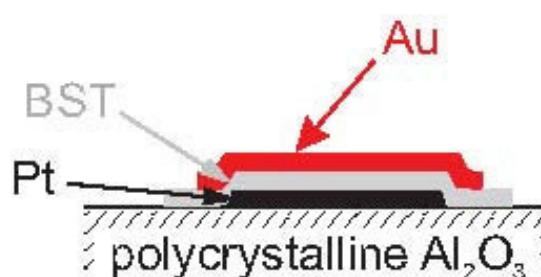


Specimen fabrication



thermal treatments in air

Name of specimen	Calcination temperature (CT)	conventional sintering (CS)	microwave sintering (MWS)
heating	5 K/min	5 K/min	20 K/min
cooling	max. 10 K/min	5 K/min	5 K/min
BST-CT700-CS	700°C, 1h	1200°C, 1h	-
BST-CT1100-CS	1100°C, 1h	1200°C, 1h	-
BST-CT700-MWS	700°C, 1h	-	1200°C, 20 min

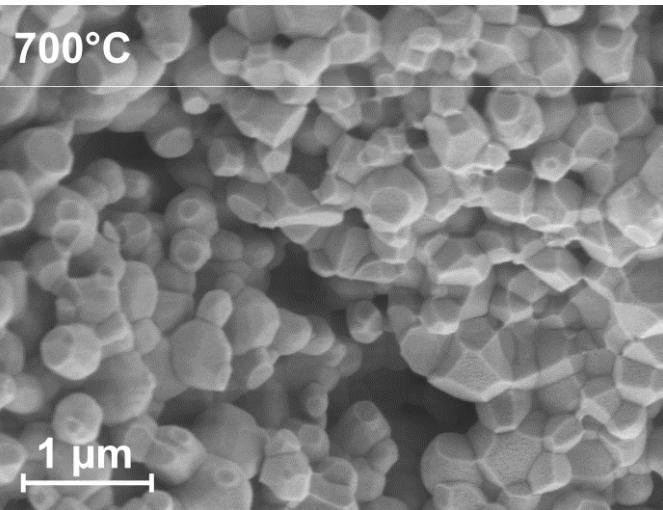


MWS: Microwave sintering
CS: conventional sintering

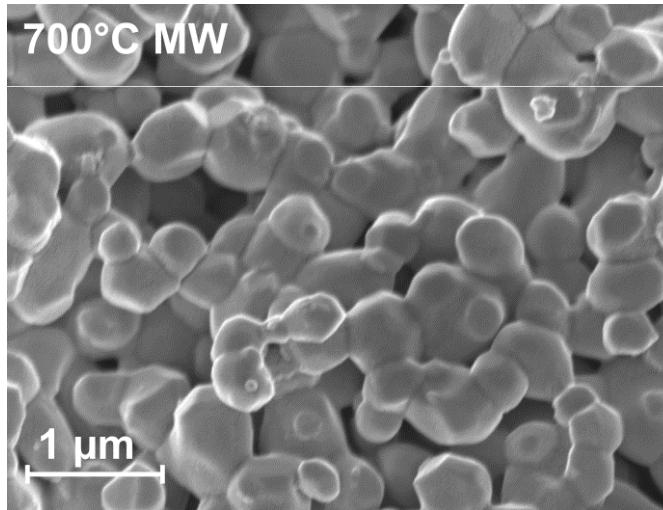
Microstructure

SEM cross-sections

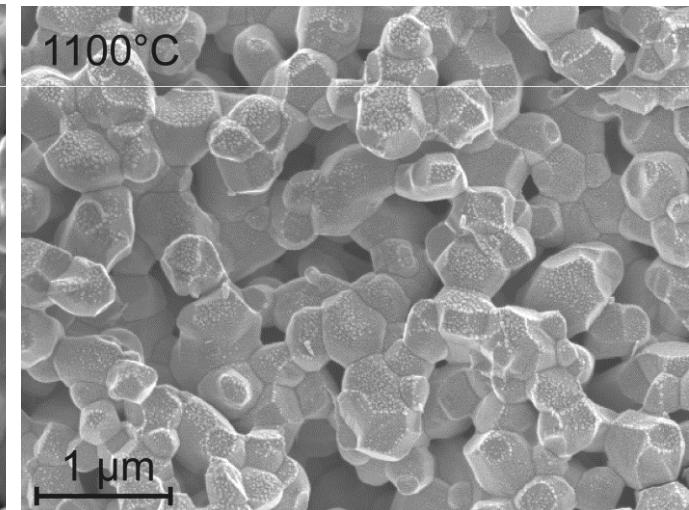
BST-CT700-CS



BST-CT700-MWS



BST-CT1100-CS



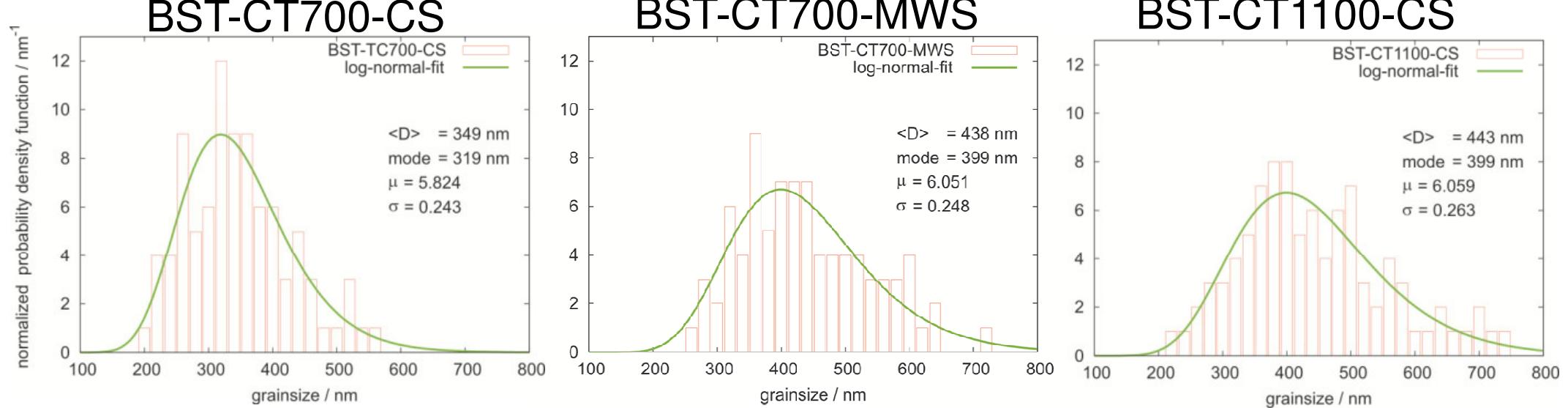
- calcined 700°C, 1h
- sintered conventionally 1200°C, 1h

- Calcined 700°C
- sintered by microwave (30 GHz) 1200°C, 20Min.

- calcined 1100°C, 1h
- sintered conventionally 1200°C, 1h

Microstructure

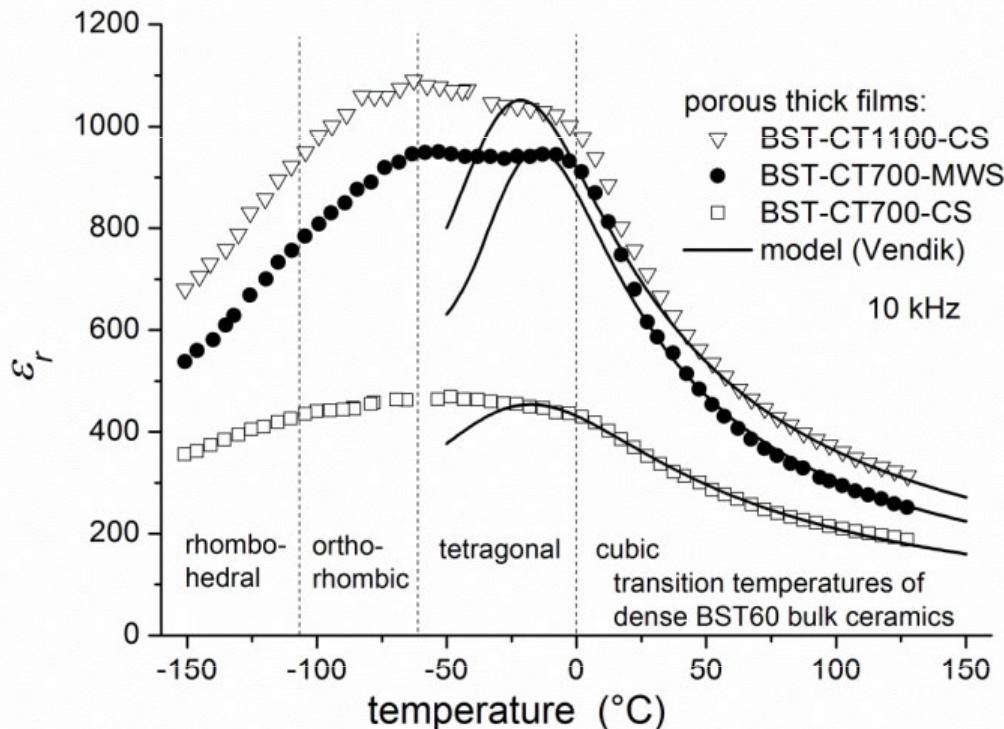
grain sizes and porosities



name of film / sample	mean grain size $\langle D \rangle$ (nm)	σ_D (nm)	mode (nm)	porosity (%)	thickness (μm)
BST-CT700-CS	349	85	319	41	10,5
BST-CT700-MWS	438	109	399	34	15,5
BST-CT1100-CS	443	116	399	33	19

Dielectric properties

Permittivity



- Low ϵ_r compared to bulk ceramics
- Decreased temperature dependence
- Broad phase transition peaks
- High calcination Temp.: increases ϵ_r
- MWS.: increases ϵ_r
- T_c is shifted to lower temperatures

modelling of the dielectric data after O. G. Vendik, S. P. Zubko, Journal of Applied Physics, 88(2000) 5343-5350

Dielectric properties

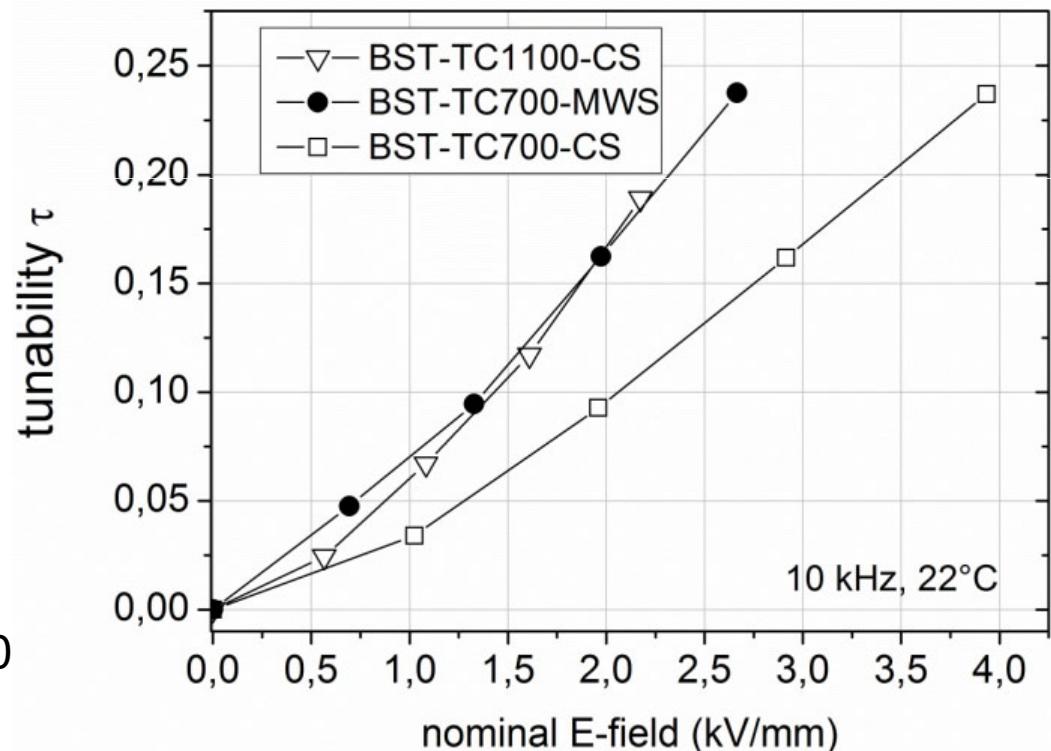
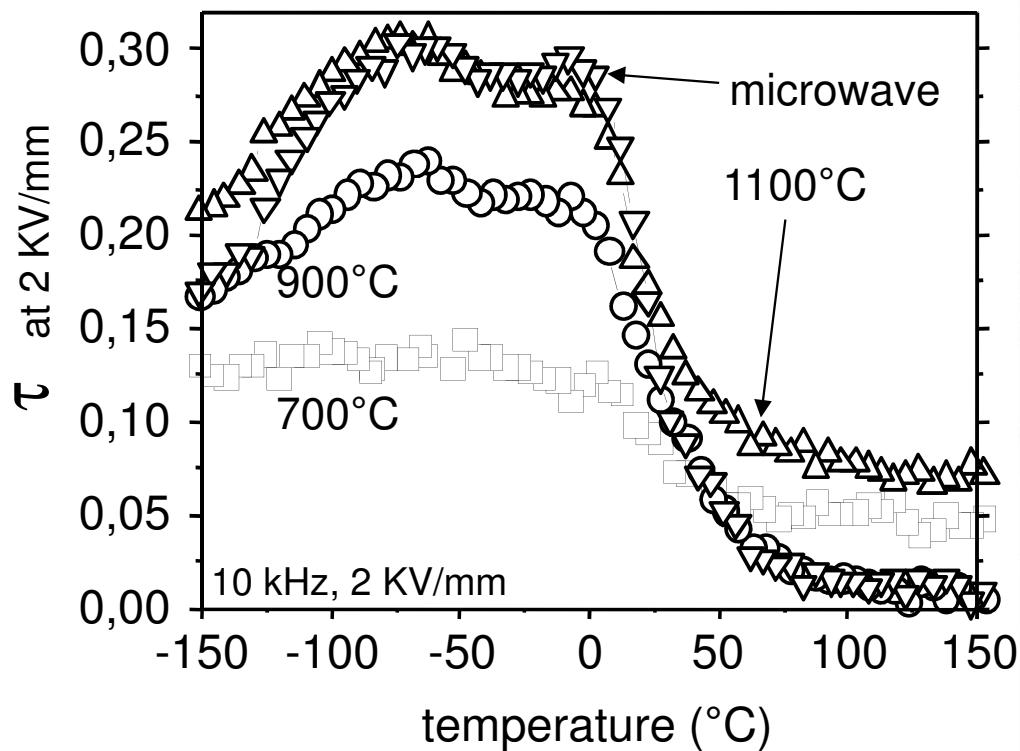
fitted parameters (Vendik model)

	T_c / K (± 3)	ξ_s (± 0.005)	mean grain size / nm	porosity / %
BST-CT700-CS	223	0.13	349	41
BST-CT700-MWS	240	0.055	438	34
BST-CT110-CS	230	0.073	443	33
BST60 ceramic	270	0.01*	-	-

- higher crystal quality after CT= 1100°C and MWS
- more bulky behavior after CT= 1100°C and MWS (T_c , ξ_s)
- *BST60 bulk-ceramics exhibit much lower values of ξ_s as suggested by Vendik ($\xi_s > 0.1$)

Dielectric properties

tunability



- high tunability due to high calcination temperature and microwave sintering
- increased tunability, compared to bulk ceramics with similar grain size

Conclusion

- thermal treatment plays a crucial role in processing of BST ceramics and thick films
- Dielectric properties are heavily dependent on microstructure and crystal quality
- porous BST thick films show decreased
 - permittivity
 - T_c
 - temperature dependence
 - cristal quality as bulk ceramics
- MWS is a high impact sintering method, comparable to long lasting conventional heating and sintering

Thank you for your attention



Thank you for collaboration and help:

- Dr. Meneskloou, Dr. Binder, Dr. Link, Dr. Zhou, Karlsruhe Institute of Technology The KIT logo features the letters "KIT" in a bold, black, sans-serif font. To the left of "KIT" are three stylized green and blue fan-like shapes. Below the letters is the text "Karlsruhe Institute of Technology".
- Prof. R. Jakoby, Dr. H. Maune, Dr. Giere, Microwave Engineering, University of Darmstadt The University of Darmstadt logo is a circular emblem featuring a profile of a head, possibly a Greek or Roman figure, with intricate patterns in the background. To the right of the emblem, the text "TECHNISCHE UNIVERSITÄT DARMSTADT" is written in a serif font.

These results will be published in the Proceedings of ISIF 2012